First Call for Papers

**Deadline for Abstract Submission : June 3, 2011**

ICPT 2011 will be held at the COEX located in Seoul, Republic of Korea during November 9 - 11, 2011. The conference will provide an international forum for academic researchers, industrial practitioners and engineers from around the world for the exchange of information on state-of-the-art research in CMP technology. ICPT 2011 promotes the exchange of opportunities, ideas, friendly relationships and research collaboration.

**Main Topics**

Areas of interest for ICPT 2011 include, but are not limited to, papers in any aspects of planarization and CMP technology.

- Copper/low-k CMP processes and control
- CMP process integration issues and reliability
- CMP defects
- CMP consumable (pads, slurries)
- CMP modeling, simulation and theory
- Metrology, characterization and test
- Advances in ECD/ECP/ECMP processes and tools
- Low-shear CMP
- CMP in emerging technologies
- Dielectric/STI CMP processes and control
- Corrosion control during CMP process
- Post CMP cleaning
- CMP equipment and metrology
- Chemical and physical mechanisms of CMP
- Advanced CMP process control techniques

**Abstracts Submission**

The Organizing committee welcomes the submission of abstracts for ICPT 2011. Prospective authors should submit an abstract, written in English. Please indicate the preference of oral or poster presentation while submitting the abstract. The deadline for submitting abstract is on June 3, 2011. Presentation of accepted papers at the conference must be in English. All papers should be submitted through website ([www.icpt2011.com](http://www.icpt2011.com)). If you have any questions, please send an email to icpt2011.korea@gmail.com.

**Key Dates**

<table>
<thead>
<tr>
<th>Date</th>
<th>Event</th>
</tr>
</thead>
<tbody>
<tr>
<td>June 3, 2011</td>
<td>Abstract submission due</td>
</tr>
<tr>
<td>July 8, 2011</td>
<td>Acceptance notification</td>
</tr>
<tr>
<td>September 2, 2011</td>
<td>Full paper submission due</td>
</tr>
</tbody>
</table>

For detailed information : [www.icpt2011.com](http://www.icpt2011.com)